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DATE MAILED: 06/15/2004

APPLICATION NO. FILING DATE FIRST NAMED INVENTOR CONFIRMATION NO. ATTORNEY DOCKET NO. 10/781,689 02/20/2004 Go Miya 500.42015VX1 3698 20457 06/15/2004 EXAMINER ANTONELLI, TERRY, STOUT & KRAUS, LLP HASSANZADEH, PARVIZ 1300 NORTH SEVENTEENTH STREET **SUITE 1800** ART UNIT PAPER NUMBER ARLINGTON, VA 22209-9889 1763

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)
Office Action Summary	10/781,689	MIYA ET AL.
	Examiner	Art Unit
	Parviz Hassanzadeh	1763
The MAILING DATE of this commu Period for Reply	nication appears on the cover sheet w	ith the correspondence address
A SHORTENED STATUTORY PERIOD THE MAILING DATE OF THIS COMMUN  Extensions of time may be available under the provision after SIX (6) MONTHS from the mailing date of this cor If the period for reply specified above is less than thirty. If NO period for reply is specified above, the maximum: Failure to reply within the set or extended period for rep Any reply received by the Office later than three months earned patent term adjustment. See 37 CFR 1.704(b).	NICATION. so of 37 CFR 1.136(a). In no event, however, may a inmunication. (30) days, a reply within the statutory minimum of thir statutory period will apply and will expire SIX (6) MON twill. by statute, cause the anolication to become Af	reply be timely filed  ty (30) days will be considered timely.  ITHS from the mailing date of this communication.
Status		
1) Responsive to communication(s) file	led on 20 February 2004	
2a)☐ This action is <b>FINAL</b> .	2b)⊠ This action is non-final.	
3) Since this application is in condition		ers, prosecution as to the merits is
closed in accordance with the prac-	tice under <i>Ex parte Quayle</i> , 1935 C.D	). 11, 453 O.G. 213.
Disposition of Claims		
4)⊠ Claim(s) <u>9-16</u> is/are pending in the	application.	
4a) Of the above claim(s) is/s		
5) Claim(s) is/are allowed.	and the second s	
6)⊠ Claim(s) <u>9-16</u> is/are rejected.		
7) Claim(s) is/are objected to.		
8) Claim(s) are subject to restri	ction and/or election requirement.	
Application Papers		
9) The specification is objected to by the	ne Examiner.	
10)⊠ The drawing(s) filed on 20 February		objected to by the Examiner
Applicant may not request that any obje	ection to the drawing(s) be held in abeyan	ce. See 37 CFR 1 85/a)
Replacement drawing sheet(s) including	g the correction is required if the drawing(	s) is objected to. See 37 CFR 1 121(d)
11)☐ The oath or declaration is objected t	o by the Examiner. Note the attached	Office Action or form PTO-152.
Priority under 35 U.S.C. § 119		
12)⊠ Acknowledgment is made of a claim	for foreign priority under 35 U.S.C. 8	119(a)-(d) or (f)
a)⊠ All b)□ Some * c)□ None of:	<b>3</b> , , , , , , , , , , , , , , , , , , ,	(=) (=) 0. ()).
<ol> <li>Certified copies of the priority</li> </ol>	documents have been received.	
<ol><li>2.   Certified copies of the priority</li></ol>	documents have been received in Ap	oplication No. 10/229.072.
<ol><li>Copies of the certified copies</li></ol>	of the priority documents have been	received in this National Stage
application from the Internation	onal Bureau (PCT Rule 17.2(a)).	
* See the attached detailed Office action	on for a list of the certified copies not r	received.
Attachment(s)		
Notice of References Cited (PTO-892)	4) Intension Se	ummary (PTO-413)
Notice of Draftsperson's Patent Drawing Review (F	PTO-948) Paper No(s)	/Mail Date
<ul> <li>Information Disclosure Statement(s) (PTO-1449 or Paper No(s)/Mail Date 2/04.</li> </ul>	PTO/SB/08) 5) ☐ Notice of Int 6) ☐ Other:	formal Patent Application (PTO-152)
Patent and Trademark Office		
OL-326 (Rev. 1-04)	Office Action Summary	Part of Paper No./Mail Date 6/2004

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## DETAILED ACTION

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claims 9-16 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nabeshima et al (JP 6-275578-A) in view of Sakamoto et al (JP 58-200,539-A).

Nabeshima et al teach a plasma processing apparatus (Fig. 3) for applying plasma treatment to a sample arranged in a vacuum process chamber 3, including plasma generation electrodes (means) 8 and 7 for generating plasma inside the vacuum process chamber 3 and . process gas introduction port (means) 4 for introducing a process gas into the chamber 3, the apparatus further comprising:

an ultrasonic oscillator 1 for imparting mechanical agitation to the apparatus in order to separate foreign matters adhered to the internal surface of the chamber 3 (abstract). The

apparatus as shown in Fig. 3 also includes a process monitoring system including light source 16 and sensing device 20.

Nabeshima et al fail to disclose detecting mechanical oscillation generated by the ultrasonic oscillator.

Sakamoto et al teach a semiconductor processing apparatus (Fig. 2) for applying plasma treatment to a sample 5 arranged in a vacuum process chamber 1, including plasma generation electrode (means) 7 for generating plasma inside the vacuum process chamber 1 and process gas introduction port (means) (not shown) for introducing a process gas into the chamber 1, the apparatus further including:

a process monitoring system comprising a transmitter 9 coupled to an ultrasonic electric pulse oscillator 13 for feeding ultrasonic pulses into the chamber; and receiver 10 coupled to an oscilloscope 12 ( detecting mechanical oscillation generated by the oscillation means in the processing apparatus) wherein the intensity of a measured signal 15 is compared with a reference signal 14 and is correlated with a sate of the processing (abstract).

Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to implement the process monitoring system as taught by Sakamoto et al in the apparatus of Nabeshima et al as an art recognized equivalent process monitoring system. See MPEP 2144.06, Art Recognized Equivalent for the Same Purpose, Substituting Equivalents Known for the Same Purpose (in re Fout, 675 F.2d 297, 213 USPQ 532 (CCPA 1982)).

Further regarding claims 9, 13, 14, 16: It is noticed that the signal received by the oscillation monitoring system of Sakamoto et al would inherently includes the mechanical oscillation generated by the oscillator 1 of Nabeshima et al.

Further regarding claims 10, 11: as shown in Fig. 3 of Nabeshima et al, the ultrasonic oscillator is arranged inside the chamber 3 and imparting mechanical oscillation to electrode 8 provided inside the chamber.

Further regarding claims 12: as shown in Fig. 2 of Sakamoto et al the transmitter and the receiver are facing each other; and the changes in the intensity of signal 15 with respect to reference signal 14 is correlated with a state of the processing. Further the measured signal would inherently include the mechanical oscillation generated by the ultrasonic oscillator 1 of Nabeshima.

Further regarding claim 15: It is held in re Harza, 274 F.2d 669, 124 USPQ 378 (CCPA 1960) that a mere duplication of parts has no patentable significance unless a new and unexpected result is produced therefore it would have been obvious to one of ordinary skill in the art at the time the invention was made to add an additional ultrasonic oscillator 1 inside the chamber above the upper electrode in order to ease the separation of foreign matters from the upper electrode; and to incorporate additional process monitoring system in order to monitor the state of the plasma along the axial direction of the plasma.

## Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Bennett et al (US Patent No. 5,387,777), Hasegawa et al (US Patent No. 5,795,399); Madan et al (US Patent No. 6,214,706 B1); and Madan et al (US Patent No. 6,427,622 B2) teach plasma processing apparatus including an oscillator for imparting mechanical oscillation to the apparatus.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Parviz Hassanzadeh whose telephone number is (571)272-1435. The examiner can normally be reached on Tuesday-Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Gregory Mills can be reached on (571)272-1439. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

P. Havengult
Parviz Hassanzadeh
Primary Examiner
Art Unit 1763

June 8, 2004